AMENDMENTS TO THE CLAIMS:

This listing of claims will replace all prior versions, and listings, of claims in the application:

- 1. (Original) A glass for a window of a semiconductor package, which is for use as a window material for a semiconductor package made of a plastic and has an average linear expansion coefficient of 120×10^{-7} /°C to 180×10^{-7} /°C at a temperature of 100 to 300°C.
- 2. (Original) A glass for a window of a semiconductor package, having an average linear expansion coefficient of 120 x 10⁻⁷/°C to 180 x 10⁻⁷/°C at a temperature of 100 to 300°C and having a U content of 5 ppb or less and a Th content of 5 ppb or less.
- 3. (Currently Amended) The glass for a window for a semiconductor package as recited in claim 1 or 2, which contains Cu and phosphorus oxide.
- 4. (Original) The glass for a window of a semiconductor package as recited in claim 3, in which a wavelength which exhibits a transmittance of 50 % is 630 nm or less in terms of a spectral transmittance at a wavelength of 400 to 700 nm when the glass has a thickness of 0.5 mm.
- 5. (Original) The glass for a window of a semiconductor package as recited in claim 3, which contains, by cationic %, 23 to 41 % of P^{5+} , 4 to 16 % of Al^{3+} , 11 to 40 % of Li^+ , 3 to 13 % of Na^+ , 12 to 53 % of R^{2+} (R^{2+} stands for Mg^{2+} , Ca^{2+} , Sr^{2+} , Ba^{2+} or Zn^{2+}) and 2.6 to 4.7 % of Cu^{2+} and contains F^- and O^2^- as anionic components.
- (Currently Amended) The A glass window for a semiconductor package, which is
 made of the glass for a window-recited in claim 1 or 2.

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7. (Original) A glass window for a semiconductor package, having a lens function and having an average linear expansion coefficient of 120×10^{-7} /°C to 180×10^{-7} /°C at a temperature of 100×100 °C.

8. (Original) A glass window for a semiconductor package, which is formed of a glass having an average linear expansion coefficient of 120×10^{-7} /°C to 180×10^{-7} /°C at a temperature of 100 to 300°C, having a U content of 5 ppb or less and a Th content of 5 ppb or less and containing Cu and phosphorus oxide, in which a wavelength which exhibits a transmittance of 50 % is 630 nm or less in terms of a spectral transmittance at a wavelength of 400 to 700 nm when the glass window has a thickness of 0.5 mm.

(Original) The glass window for a semiconductor package as recited in claim 6, which
is a precision press-molded product.

10. (original) A process for the production of a glass window for a semiconductor package, which comprises precision-press-molding a lens-shaped window material glass made of a glass having an average linear expansion coefficient of 120 x 10⁻⁷/°C to 180 x 10⁻⁷/°C at a temperature of 100 to 300°C.

- 11. (Original) A semiconductor package comprising the glass window for a semiconductor package recited in claim 6, a semiconductor device and a package encasing the semiconductor device, the glass window having an attaching portion made of a plastic material.
- 12. (Original) A semiconductor package as recited in claim 11, wherein the semiconductor device is an image-sensing device.